

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Jeffrey HUNG et al.

Application No.: 09/002,007

Filed: December 31, 1997

For: ETCHING PROCESS FOR ORGANIC
ANTI-REFLECTIVE COATING



Group Art Unit: 1765

Examiner: L. VINH

RECEIVED

MAY 21 1999

GROUP 1700

INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In accordance with the duty of disclosure as set forth in 37 C.F.R. §1.56, Applicants hereby submit the following information which was cited in an International Search Report (copy enclosed) issued in a corresponding PCT application (PCT/US98/26226) mailed on April 22, 1999. Pursuant to 37 C.F.R. § 1.98, a copy of each of the documents cited is enclosed.

European Patent Publication No. 0 407 169, January 9, 1991;
PCT Patent Publication No. WO97/07145, February 27, 1997; and
"Dry Etching of Bottom Anti-Reflective-Coat and its Application to Gate Length Control", A. Nishizawa, et al., IEEE International Symposium on Semiconductor Manufacturing Conference Proceedings, XP-002099210, October 6-8, 1997, pages F13-F16.

I, the undersigned, hereby certify that each item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement.

To assist the Examiner, the documents are listed on the attached form PTO-1449. It is respectfully requested that an Examiner initialled copy of this form be returned to the undersigned.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

By: 
Peter K. Skiff
Registration No. 31,917

P.O. Box 1404
Alexandria, Virginia 22313-1404
(703) 836-6620

Date: May 19, 1999